

DOCKET NO: 284119US6XPCT

**IN THE UNITED STATES PATENT & TRADEMARK OFFICE**

IN RE APPLICATION OF :  
KATSUTOSHI TAKAGI, ET AL. : EXAMINER: YANG, JIE  
SERIAL NO: 10/564,502 :  
FILED: JANUARY 13, 2006 : GROUP ART UNIT: 1793  
FOR: AG BASE SPUTTERING TARGET :  
AND PROCESS FOR PRODUCING THE  
SAME

**RESPONSE TO RESTRICTION REQUIREMENT**

COMMISSIONER FOR PATENTS  
ALEXANDRIA, VIRGINIA 22313

SIR:

In response to the Restriction Requirement stated in the Official Action dated February 27, 2009, Applicants elect Group I, Claims 1-6 and 9-11, drawn to a product of a silver alloy-sputtering target with uniform grain size.

Therefore, it is respectfully requested that a full examination on the merits of Claims 1-6 and 9-11 be conducted.

Respectfully submitted,

OBLON, SPIVAK, McCLELLAND,  
MAIER & NEUSTADT, P.C.



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